Extremely Low Dark Current, Polymer Donor PD1300T1 For SWIR-OPD



1-Material Inc

2290 Chemin St-Francois Dorval, Quebec H49P 1K2, Canada

Organic Nano Electronic (ONE=1) Materials for these who understand quality

Technical Data Sheet

1M Material: PD1300T1

Common Name: PD-1300T1, SWIR-OPD-1300T1, PQPr-55

Potential Applications: Polymeric donor for SWIR-OPD with peak sensitivity approaches 1300nm,

extremely low dark current and high detectivity.

Chemical Structure:

Appearance: Deep brown to black solid

Molecular Weight: Mw > 100K, PDI ~ 3 (GPC, PS standards)

Energy Level: LUMO=-4.16eV; HOMO=-4.91eV; Eg=0.75eV.

Purity: 99% (basing on NMR of monomers)

Shelf life: 6 months (unopened)

Safety: Please consult Material Safe Data Sheet (MSDS) before using

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Suggested device fabrication procedure, example and reference only

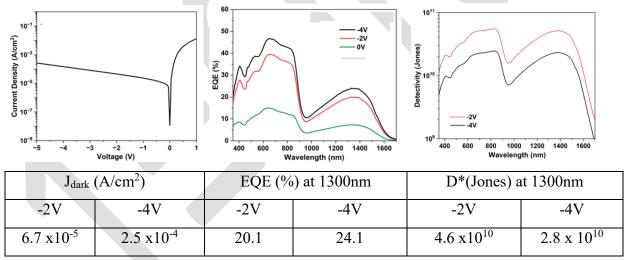
Glass/ITO/AZO(40nm)/PD-1300-T1:N1(140nm)/MoO_x(8nm)/Ag(100nm):

- 1. Prepare the active ink PD1300T1(donor):N1 (acceptor)=1:2; total 30mg/mL in o-xylene. Best storage in nitrogen otherwise dry box (relatively humidity <20% is recommended)

 If the ink has been left standing on shelf for a while (>60min), rehesting is recommended to the uniformity of the ink, else the viscosity of the ink will increase due to gelation.

 Reheating ink at 100 °C for 30min under nitrogen protection and allow ink to cool down.
- 2. Deposit AZO(N-21x-Flex) ink on ITO substrate by spin-coating at 3000rpm for 30s. Followed by 50 mins annealing at 200 $^{\circ}$ C in the air to form \sim 40nm electron transporting layer.
- 3. Place AZO/ITO substrate on a spin-coater and flood with ink, then spin at 900-1200 rmp for 50s, and finish coating with 5-7 sec at 3000 rpm to throw off any ink drops that accumulated in the corners of the substrate; anneal the as-cast film at 100 °C for 5 min to have a thickness of ~140nm.
- 4. Deposit MoO_x (8 nm) and Ag (100 nm) under a vacuum pressure below $1x10^{-6}$ torr. Alternatively, ZnO can replace AZO to have comparable performance.

Typical performance:



Note: D*: the shot noise-limited detectivity

References: Adv. Optical Mater. 2025, e01536 (DOI: 10.1002/adom.202501536

Remarks: PD1300T1is patented and produced by Raynergy Tek Incorporation. 1-Material Inc has

been granted the exclusive right to provide these materials in North America under the

trademark of 1-Material.

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